

FIG. 1

100200047 • 126701

100020007-120701

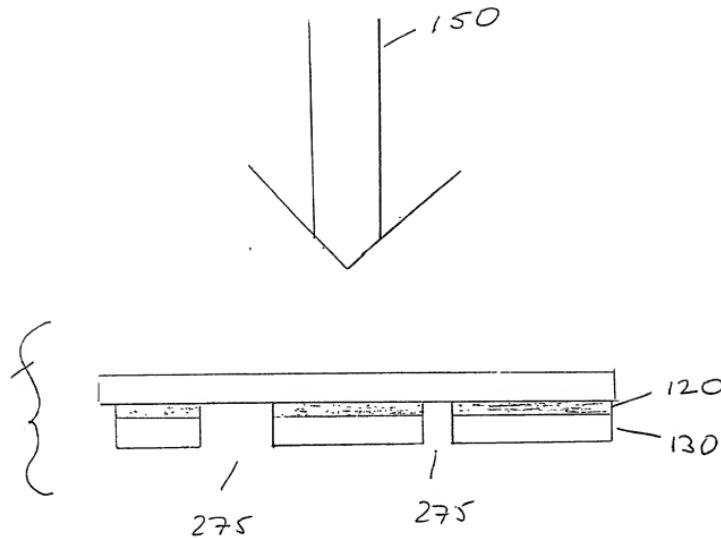


FIG. 2

EXPRESS MAIL NO. EL844534677US, MAILED 12/7/2001

M0635/7073

Sheet 3 of 6

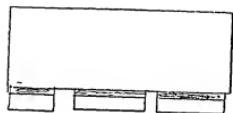
Attenuating Phase Shift Mask for Photolithography

Inventor or Identifier: Rothschild, et al.

300



— 200



335



350



FIG. 3

100020047-1120701

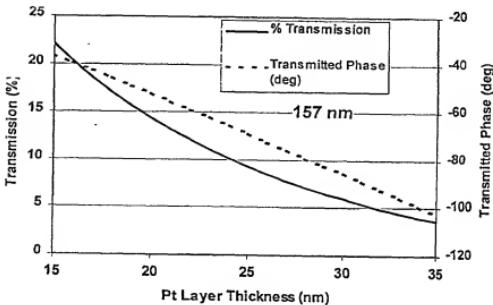


FIG 4a

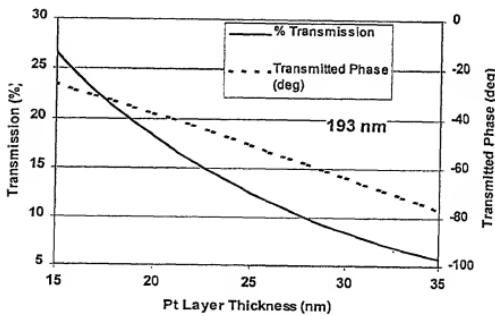


FIG 4b

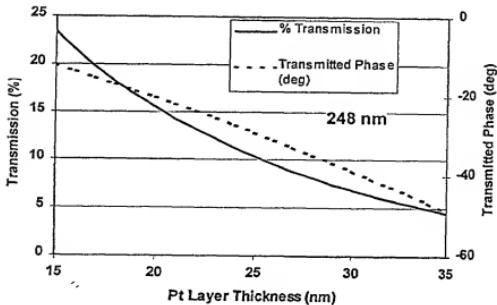
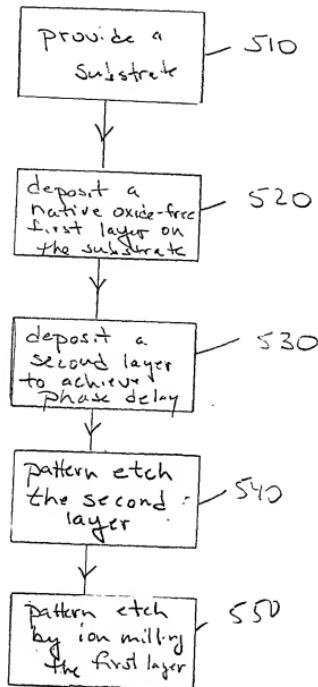


FIG 4c

500



10020047-120701

FIG 5a

SSO

10020047-A200701

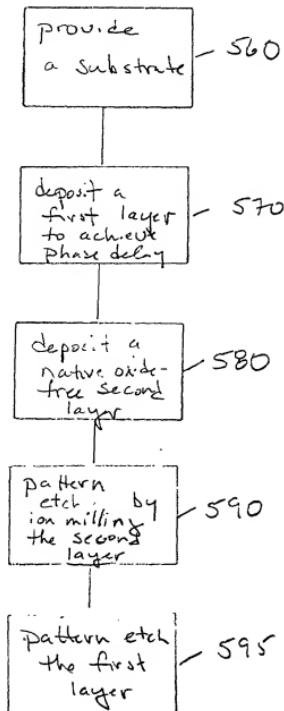


FIG 5b